



# STW45NM50

N-CHANNEL 550V @ Tjmax - 0.08Ω - 45A TO-247

MDmesh™ MOSFET

**Table 1: General Features**

TYPE	V <sub>DSS</sub> (@Tjmax)	R <sub>DS(on)</sub>	I <sub>D</sub>
STW45NM50	550V	< 0.1Ω	45 A

- TYPICAL R<sub>DS(on)</sub> = 0.08Ω
- HIGH dv/dt AND AVALANCHE CAPABILITIES
- 100% AVALANCHE TESTED
- LOW INPUT CAPACITANCE AND GATE CHARGE
- LOW GATE INPUT RESISTANCE
- TIGHT PROCESS CONTROL AND HIGH MANUFACTURING YIELDS

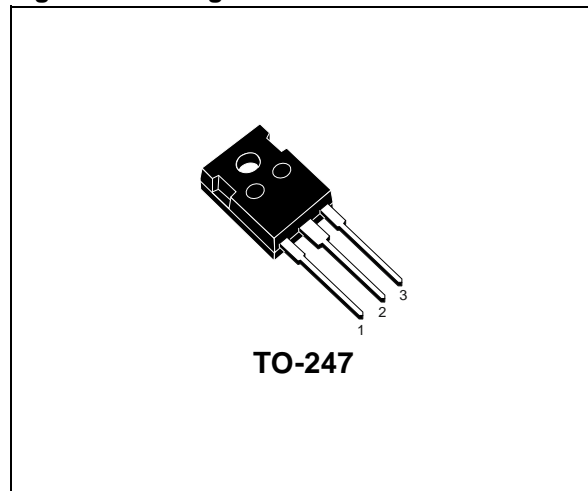
## DESCRIPTION

The MDmesh™ is a new revolutionary MOSFET technology that associates the Multiple Drain process with the Company's PowerMESH™ horizontal layout. The resulting product has an outstanding low on-resistance, impressively high dv/dt and excellent avalanche characteristics. The adoption of the Company's proprietary strip technique yields overall dynamic performance that is significantly better than that of similar competition's products.

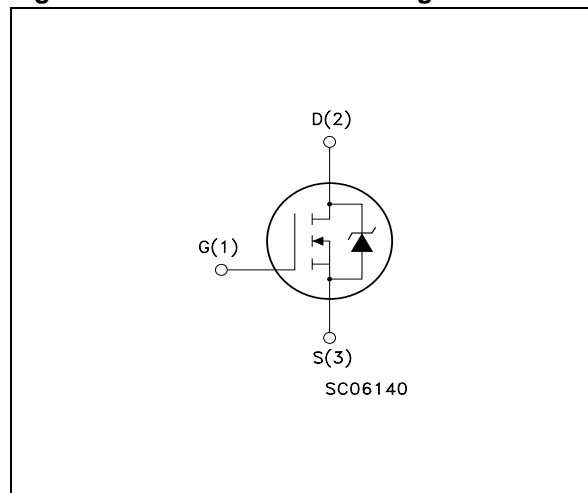
## APPLICATIONS

The MDmesh™ family is very suitable for increasing power density of high voltage converters allowing system miniaturization and higher efficiencies.

**Figure 1: Package**



**Figure 2: Internal Schematic Diagram**



**Table 2: Order Codes**

SALES TYPE	MARKING	PACKAGE	PACKAGING
STW45NM50	W45NM50	TO-247	TUBE

**Table 3: Absolute Maximum ratings**

Symbol	Parameter	Value	Unit
$V_{GS}$	Gate- source Voltage	$\pm 30$	V
$I_D$	Drain Current (continuous) at $T_C = 25^\circ\text{C}$	45	A
$I_D$	Drain Current (continuous) at $T_C = 100^\circ\text{C}$	28.4	A
$I_{DM} (*)$	Drain Current (pulsed)	180	A
$P_{TOT}$	Total Dissipation at $T_C = 25^\circ\text{C}$	417	W
	Derating Factor	2.08	W/°C
dv/dt (1)	Peak Diode Recovery voltage slope	15	V/ns
$T_{stg}$	Storage Temperature	-65 to 150	°C
$T_j$	Max. Operating Junction Temperature	150	°C

(\*)Pulse width limited by safe operating area

(1) $I_{SD} \leq 45\text{A}$ ,  $di/dt \leq 400\text{A}/\mu\text{s}$ ,  $V_{DD} \leq V_{(BR)DSS}$ ,  $T_j \leq T_{JMAX}$ .**Table 4: Thermal Data**

Rthj-case	Thermal Resistance Junction-case	Max	0.3	°C/W
Rthj-amb	Thermal Resistance Junction-ambient	Max	30	°C/W
$T_I$	Maximum Lead Temperature For Soldering Purpose		300	°C

**Table 5: Avalanche Characteristics**

Symbol	Parameter	Max Value	Unit
$I_{AR}$	Avalanche Current, Repetitive or Not-Repetitive (pulse width limited by $T_j$ max)	20	A
$E_{AS}$	Single Pulse Avalanche Energy (starting $T_j = 25^\circ\text{C}$ , $I_D = I_{AR}$ , $V_{DD} = 35\text{V}$ )	810	mJ

**ELECTRICAL CHARACTERISTICS** ( $T_{CASE} = 25^\circ\text{C}$  UNLESS OTHERWISE SPECIFIED)**Table 6: On/Off**

Symbol	Parameter	Test Conditions	Min.	Typ.	Max.	Unit
$V_{(BR)DSS}$	Drain-source Breakdown Voltage	$I_D = 250\ \mu\text{A}$ , $V_{GS} = 0$	500			V
$I_{DSS}$	Zero Gate Voltage Drain Current ( $V_{GS} = 0$ )	$V_{DS} = \text{Max Rating}$ $V_{DS} = \text{Max Rating}$ , $T_C = 125^\circ\text{C}$			10 100	$\mu\text{A}$ $\mu\text{A}$
$I_{GSS}$	Gate-body Leakage Current ( $V_{DS} = 0$ )	$V_{GS} = \pm 30\text{V}$			$\pm 100$	nA
$V_{GS(th)}$	Gate Threshold Voltage	$V_{DS} = V_{GS}$ , $I_D = 250\ \mu\text{A}$	3	4	5	V
$R_{DS(on)}$	Static Drain-source On Resistance	$V_{GS} = 10\text{V}$ , $I_D = 22.5\text{A}$		0.08	0.1	$\Omega$

## ELECTRICAL CHARACTERISTICS (CONTINUED)

Table 7: Dynamic

Symbol	Parameter	Test Conditions	Min.	Typ.	Max.	Unit
$g_{fs}$ (2)	Forward Transconductance	$V_{DS} > I_{D(on)} \times R_{DS(on)max}, I_D = 22.5A$		20		S
$C_{iss}$ $C_{oss}$ $C_{rss}$	Input Capacitance Output Capacitance Reverse Transfer Capacitance	$V_{DS} = 25V, f = 1 \text{ MHz}, V_{GS} = 0$		3700 610 80		pF pF pF
$C_{oss \text{ eq.}}$ (3)	Equivalent Output Capacitance	$V_{GS} = 0V, V_{DS} = 0V \text{ to } 400V$		325		pF
$R_G$	Gate Input Resistance	$f=1 \text{ MHz}$ Gate DC Bias = 0 Test Signal Level = 20mV Open Drain		1.7		$\Omega$
$t_{d(on)}$ $t_r$	Turn-on Delay Time Rise Time	$V_{DD} = 250V, I_D = 24 \text{ A}$ $R_G = 4.7\Omega, V_{GS} = 10 \text{ V}$ (see Figure 14)		40 35		ns ns
$t_{d(off)}$ $t_f$ $t_c$	Turn-off Delay Time Fall Time Cross-over Time	$V_{DD} = 400 \text{ V}, I_D = 45 \text{ A}, R_G = 4.7\Omega,$ $V_{GS} = 10 \text{ V}$ (see Figure 14)		18 23 44		ns ns ns
$Q_g$ $Q_{gs}$ $Q_{gd}$	Total Gate Charge Gate-Source Charge Gate-Drain Charge	$V_{DD} = 400V, I_D = 45 \text{ A},$ $V_{GS} = 10V$ (see Figure 18)		87 23 42	117	nC nC nC

Table 8: Source Drain Diode

Symbol	Parameter	Test Conditions	Min.	Typ.	Max.	Unit
$I_{SD}$	Source-drain Current				45	A
$I_{SDM}$ (3)	Source-drain Current (pulsed)				180	A
$V_{SD}$ (2)	Forward On Voltage	$I_{SD} = 45 \text{ A}, V_{GS} = 0$			1.5	V
$t_{rr}$ $Q_{rr}$ $I_{RRM}$	Reverse Recovery Time Reverse Recovery Charge Reverse Recovery Current	$I_{SD} = 40 \text{ A}, di/dt = 100A/\mu s,$ $V_{DD} = 100 \text{ V}, T_j = 25^\circ C$ (see Figure 16)		520 7.8 30		ns $\mu C$ A
$t_{rr}$ $Q_{rr}$ $I_{RRM}$	Reverse Recovery Time Reverse Recovery Charge Reverse Recovery Current	$I_{SD} = 40 \text{ A}, di/dt = 100A/\mu s,$ $V_{DD} = 100 \text{ V}, T_j = 150^\circ C$ (see Figure 16)		680 11.2 33		ns $\mu C$ A

(2) Pulsed: Pulse duration = 300  $\mu s$ , duty cycle 1.5 %.(3)  $C_{oss \text{ eq.}}$  is defined as a constant equivalent capacitance giving the same charging time as  $C_{oss}$  when  $V_{DS}$  increases from 0 to 80%  $V_{DSS}$ .

Figure 3: Safe Operating Area

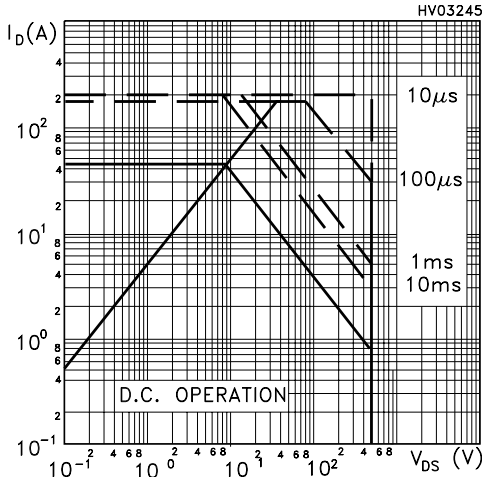


Figure 4: Output Characteristics

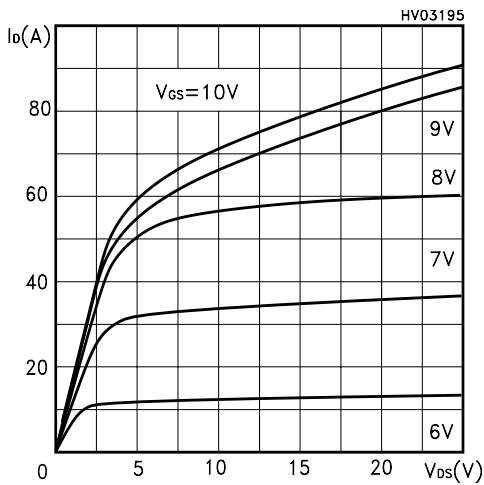


Figure 5: Transconductance

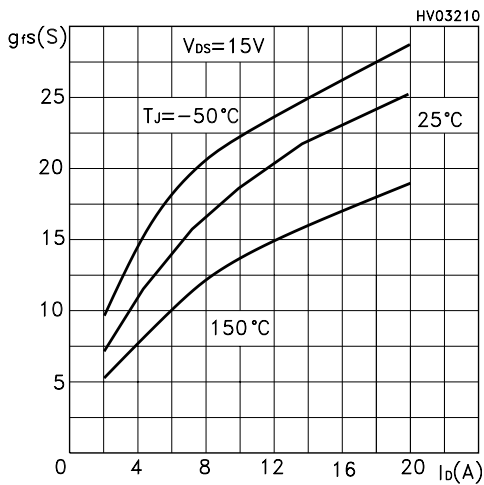


Figure 6: Thermal Impedance

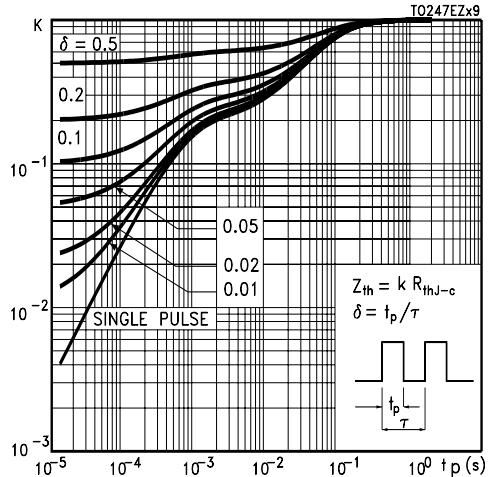


Figure 7: Transfer Characteristics

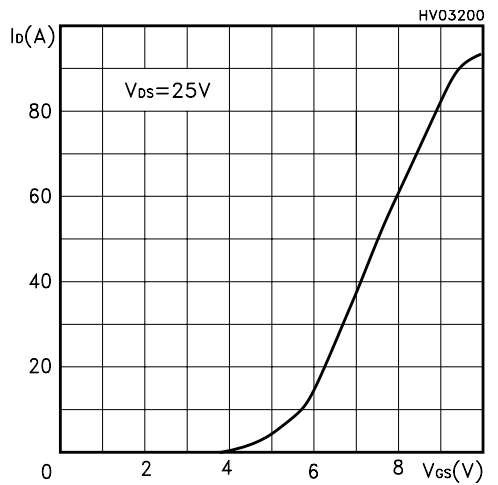


Figure 8: Static Drain-source On Resistance

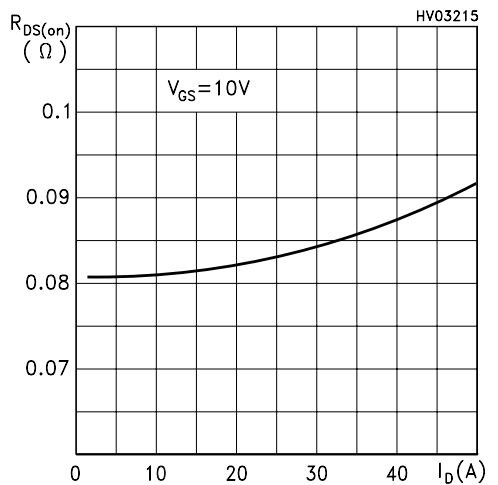


Figure 9: Gate Charge vs Gate-source Voltage

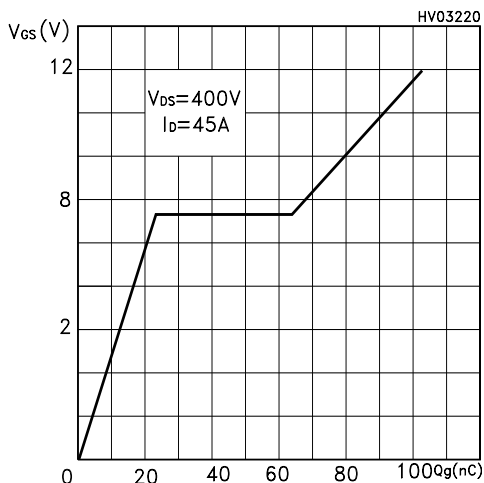


Figure 10: Normalized Gate Threshold Voltage vs Temperature

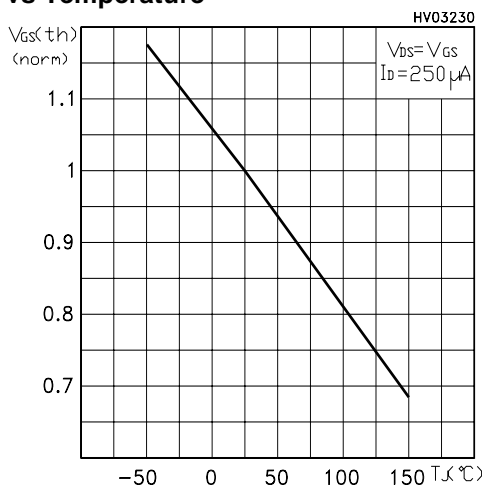


Figure 11: Source-Drain Diode Forward Characteristics

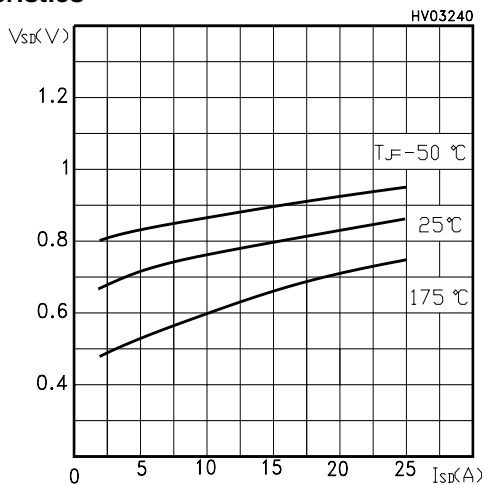


Figure 12: Capacitance Variations

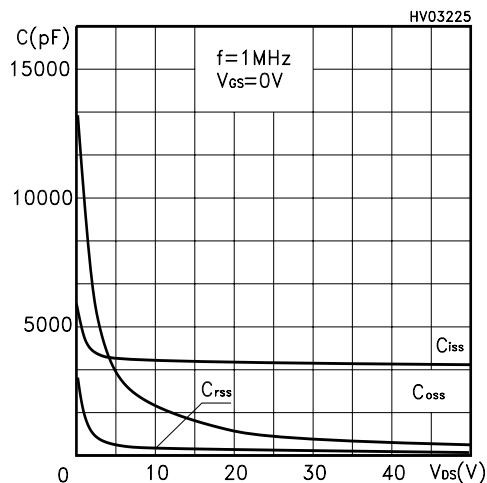


Figure 13: Normalized On Resistance vs Temperature

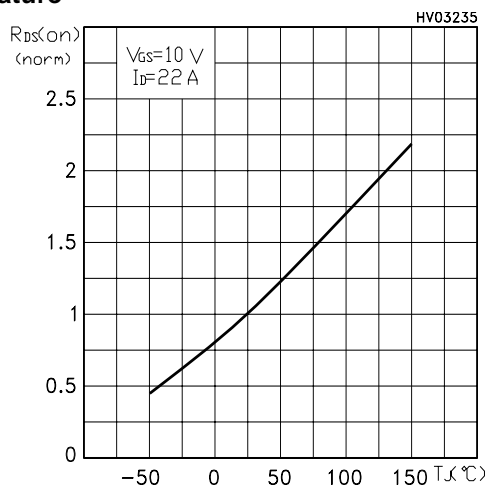


Figure 14: Unclamped Inductive Load Test Circuit

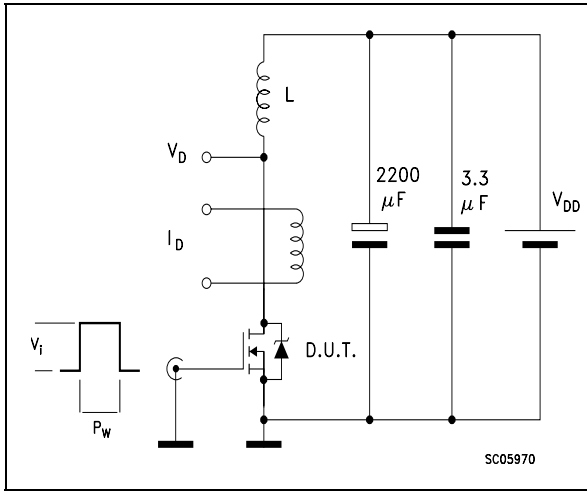


Figure 15: Switching Times Test Circuit For Resistive Load

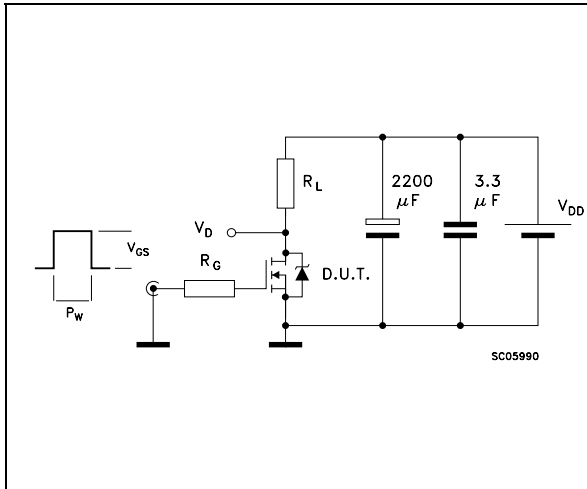


Figure 16: Test Circuit For Inductive Load Switching and Diode Recovery Times

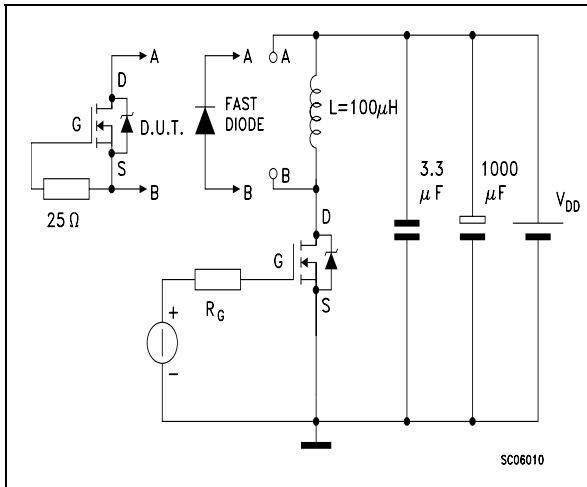


Figure 17: Unclamped Inductive Waferform

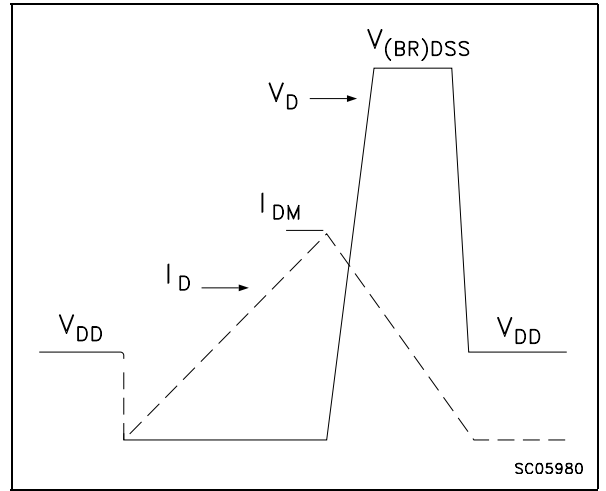
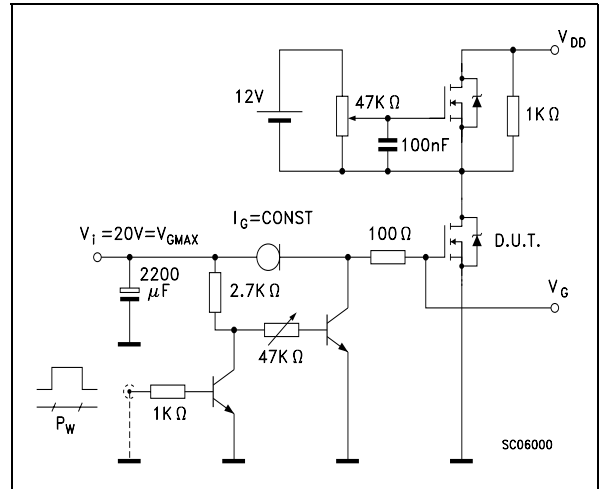


Figure 18: Gate Charge Test Circuit





**Table 9: Revision History**

<b>Date</b>	<b>Revision</b>	<b>Description of Changes</b>
30/Mar/2005	2	Modified value in table 7



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